



Please Enter  
Haichu Pham  
2/4/06

Response Under 37 CFR § 1.116  
Expedited Procedure - Group 2861

ILW  
AFB

03500.017428

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)	
	:	Examiner: H. Pham
HAJIME MOTOYAMA	)	
	:	Group Art Unit: 2861
Application No.: 10/621,417	)	
	:	
Filed: July 18, 2003	)	
	:	
For: LASER EXPOSING	)	
APPARATUS	:	January 25, 2006

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

SUPPLEMENTAL AMENDMENT AFTER FINAL REJECTION  
AND  
RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT

Sir:

In response to the Final Office Action dated October 5, 2005 (the term for responding to which having been extended to February 5, 2006 by the accompanying Petition For Extension Of Time), and to the Notice of Non-Compliant Amendment dated January 13, 2006, please amend the above-identified application, as follows: